

Your Vision, Our Future





*All brands are trademarks or registered trademarks of their respective owners.

OLYMPUS CORPORATION has obtained ISO9001/ISO14001

Illumination devices for microscope have suggested lifetimes. Periodic inspections are required. Visit our Website for details.

Specifications are subject to change without any obligation on the part of the manufacturer.



www.olympus.com

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METALLURGICAL MICROSCOPES

BX2M/MX51

Power and flexibility to perform multiple inspections with outstanding efficiency.

The BX2M*/MX51 microscope lineups offer the stages of a unique X/Y travel range in 50mm through 150mm.

Outstanding UIS2 optical performance.

Excellent image clarity and superb resolution for all inspection demands.

Greater system flexibility with unprecedented freedom to select and combine components.

Logical layout for superior operation.

Newly employed arm integrated reflected light illuminator for diverse applications.

 * BX2M series comprises BX51(M), BX41M-LED, BX51-IR, BXFM(S) and so forth.





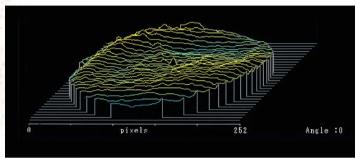
EXCELLENT OPTICS

New standard of the UIS2 optics, wavefront aberration control guarantees the world's highest level imaging, even further.



A new standard of the objective lens performance, using wavefront aberration control.

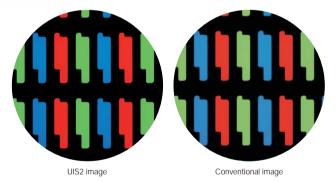
The Olympus UIS2 objective lenses set a new standard, with wavefront aberration control in addition to common performance standards of N.A. and W.D. Olympus challenges farther highest order optics which has not been fulfilled by the conventional standards. We offer excellent performance objective lenses by minimizing the aberrations that lower resolution.



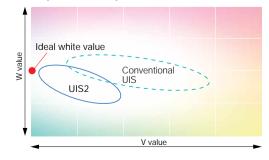
An example of 3D display of a wave front measured with a laser interferometer. The flatter the surface of the lens, the better the aberration correction becomes

Natural color reproduction faithful to the specimen.

UIS2 objective lenses realize natural color reproduction without any coloration by using stringently selected high transmittance glass and advanced coating technology that realizes high transmittance which is flat over an ultra-wide band wavelength. In addition, since the total optical system, including the tube lens is designed to reproduce a natural color, clear images faithful to the specimen are obtained even with digital imaging.



Color temperature comparison



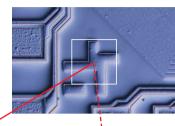
A comparison of the color temperature of UIS2 objective lenses and conventional UIS objective lenses. The color temperature of the UIS2 objective lenses is within a range which is very close to the color temperature target, which represents ideal white value.

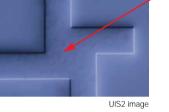
UIS2 objective lenses with excellent image parcentricity.

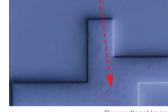
In high power Semi-apochromatic UIS2 objective lenses, centration tolerance between objective lenses on the microscope nosepiece improved by a factor of 2 so that the image never fail to keep the

image within the center of the field of view even with digital camera. Centration of the image between objective lenses allows for fast and fatigue free operation.

* 50x or higher power in both MPLFLN and LMPLFLN series



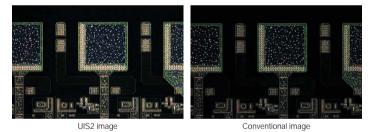




Conventional image

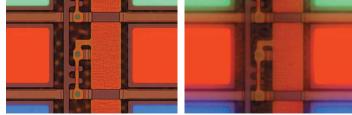
The brightest Darkfield image than ever.

New Semi-apochromatic objective lens series improves Darkfield brightness and significantly enhances sensitivity and allows quick detection of defects in the small diameter wafers used in today's smaller sensors and other high performance electronic devices.



Glass thickness corrected objective lenses handle various glass thicknesses.

LCPLFLN-LCD objective lenses, accurately correct the spherical aberration which could become issue when viewing through glass substrates, are provided. The 20x and 50x objective lenses are useful when looking through glass thicknesses of 0 to 1.2 mm and the 100x objective lens is corrected for glass thicknesses up to 0.7 mm seamlessly.



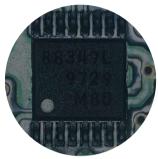
Glass thickness corrected image

Non corrected image

Removes spot flare during ultra low magnification observation.

When a low reflection specimen is observed in ultra low power magnification, spot flare hinder precise observation. In UIS2 ultra low magnification observation, a depolarizer built into the objective lens end removes spot flare and, a clear, high contrast image is obtained by combining a set of polarizer and analyzer plate.

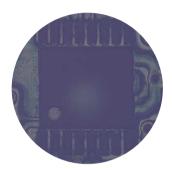
*1.25x and 2.5x objective lenses available

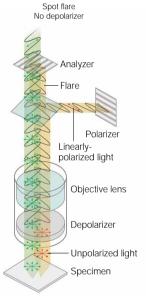


MPLFLN1.25x UIS2

Spot flare removal principle conceptual diagram.

Since the light reflected from the surface of the objective lenses is the linearly-polarized light "as is", it is eliminated by analyzer at Crossed Nicol position and has no affect on the image. On the other hand, the light passed through the depolarizer at the end of the objective lens becomes unpolarized light, and when the unpolarized light reflected from the specimen passes through the analyzer, only the linearly-polarized light that matches the vibration direction of the analyzer passes through and forms an image.





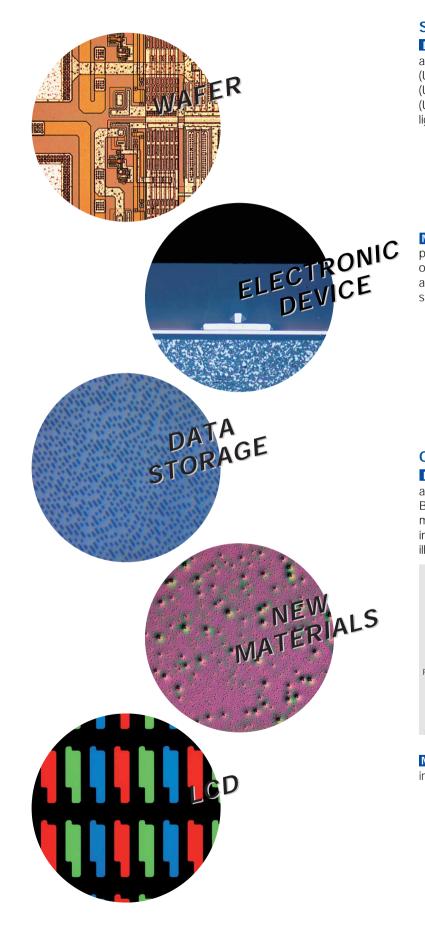
Promotes environmentally-friendly ecologization and weight reduction.

Olympus was the first to consider the environment and to tackle manufacturing ecology. As part of this, the UIS2 optical system uses eco-friendly glass free of lead and arsenic. In addition, the major Semi-apochromatic UIS2 objective lenses are lightened by approximately 2/3. This contributes to prevention of environmental pollution, improvement of operability of objective lenses replacement, etc.

*Some UIS2 objective lenses are the same weight as conventional objective lenses

SYSTEM VERSATILITY

Wide choice of handy accessories to meet the full range of microscopy inspection needs.



Stage selection and adapter plates.

BX Various special stages and adapter plates are provided: a 100 x 100 mm stage plate (U-MSSP4), a wafer holder plate (U-WHP2) for 3- and 4-inch wafers and extra-large stages (U-SIC4R2 and U-SIC4L2), allowing the use of a glass plate (U-MSSPG) for transmitted

light observations.



MX The MX51 accommodates a 6 inch wafer holder and a glass plate in combination with 150 mm stage, MX-SIC6R2 and also

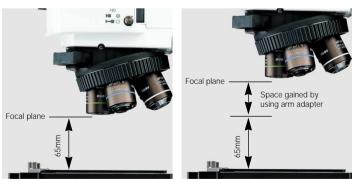
offers more versatile holders and plates with 100 mm stage, U-SIC4R2.



U-SIC4R2 Ø BH3-SPG6 BH3-SP6
 BH3-WHP6 U-MSSP4 U-WHP2
 BH2-WHR43 BH2-WHR54
 BH2-WHR65

Observation of thick samples.

BX BX41M-LED/BX51M Upright Incident Microscope System accommodates up to 65mm high specimen as a standard. Besides, the reflected light illuminator, integrated into the microscope arm gives them an extra height degree of flexibility, by inserting an arm adapter between the microscope and the illuminator.



MX The standard maximum sample thickness is 30mm. Insert the intermediate attachment to accommodate thicker samples.



Improved efficiency with the motorized revolving nosepiece.

Various revolving nosepieces including motorized ones which can be directly operated by blind-touch control pad are offered. The motorized nosepieces improve observation efficiency and eliminate particle shedding (type C). The motorized revolving nosepiece can be attached to all reflected light illuminators and microscope frames.



Diverse manual-type revolving nosepiece including perfect parcentricity type .

The quintuple BD revolving nosepiece U-P5BDRE and sextuple revolving nosepiece with centering mechanism U-P6RE enables perfect parcentricity between three objective lenses. There is no image center displacement, even when switching from low to high magnifications, an added convenience.



Fiber illumination system for all reflected light illuminators.

Cold light illumination, using fiber light guides, is available for all reflected light illuminators. Fiber light illumination systems such as the LG-PS2 utilize a bright 12V100W halogen lamp. * The type of model varies by country in use.



Reflected light illuminators are compatible with a variety of light sources.

For flexibility in high intensity and long lifetime illumination, Olympus lamphouses offer Halogen, Xenon and Mercury bulb options. The apochromatic collector lens system for halogen, xenon and mercury light sources compensates for chromatic aberrations from the visible to near-infrared light.



Transmitted light observation.

BX Various transmitted light condensers compatible with true transmitted light observation are available. Choose the condenser matched to the purpose.



MX The combination of a transmitted illumination unit with the 150mm stage, MX-SIC6R2 enables transmitted light brightfield observation of samples up to 2mm thick, with an illumination range of 100 x 100mm. The slim-profiled illumination unit is designed for

minimal effect on the stage operation and is useful for observations of samples such as MEMS (Micro Electronics Mechanical Systems) sensors and other optical/optronic components.



Filter sliders for flexible illumination.

A variety of filter sliders are provided for such filters as UV-cut, color temperature change and color enhancement.

ERGONOMIC DESIGN Improved design signals new advance in ergonomics.



Easy focusing and convenient "either-side" attachment of the fine focusing knob.

BX The fine focusing knob can be removed and attached to either side of the microscope to suit right/left-handed operators. The control knob's tactile cover allows light-touch fingertip operation, while the fine focus mechanism is extremely accurate, even at high magnifications.

Agile stage movement and coarse/fine movement interchange.

MX Two stage sizes are selectable, 150mm (MX-SIC6R2) and 100 mm(U-SIC4R2). The 150mm stage has a built-in clutch lever, which enables quick location of specimens on the stage without diverting the operator's view, allowing quick, easy inspections.

Repositioned optical controls for smoother performance.

MX Controls for focusing and light intensity adjustment are placed closer together, so that both can be operated with one and the same hand.



Anti-static treatment prevents dust contaminating the sample.

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MX The frame and 6-inch stage are coated to prevent static build-up. * Use special metal plate

Range of tilting observation tubes to assist operator comfort.

U-TBI-3 tilting tube is provided for binocular observation, and the U-SWETTR-5, MX-SWETTR observation tubes for documentation.

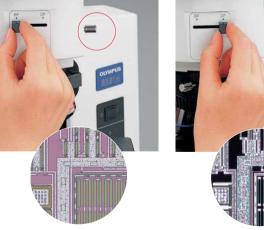
This range of choice lets each operator achieve the most suitable eyepoint and an ergonomic posture, resulting in greatly reduced fatigue for longduration observations.





Integrated ND filter for more comfortable switching between brightfield/darkfield observation methods.

The brightfield/darkfield reflected light illuminator features an integrated ND filter that protects the operator's eye by preventing sudden, drastic changes in brightness. This integrated function can be disengaged manually.





Brightfield observation

Darkfield observation

Nomarski DIC system provides an optimum image suited to the sample.

Olympus Nomarski DIC observation uses a simple observation switching slider type single prism system. Three different DIC prisms are provided: the U-DICR for all imaging applications, high resolution U-DICRH, and high contrast U-DICRHC, so that the best resolution and contrast matched to the state of the sample are obtained. Since

the exit pupil position of the objective lens is standardized by the series, the position of the DIC prism does not have to be switched when the magnification was changed by switching the objective lens, e.g. MPLFLN series 5x through 150x.





U-DICR

U-DICRHC

Polarizer/analyzer plates are interlocked for easy slide IN/OUT.

The interlocked polarizer/analyzer slide IN/OUT on the optical axis by one action so that the switching between Nomarski DIC/POL

and other observation methods is performed speedy. In addition, the polarizer and analyzer are designed so that the reflected light illuminator slide-in and slide-out operations can be performed from either the left or right side.

Simultaneous attachment of digital camera and video camera.

The intermediate trinocular unit U-TRU, combined with the tilting observation tube U-TBI-3 makes simultaneous attachment of digital and video documentation equipment possible.



Convenient magnification changer.

The magnification changer applies an additional 2x magnification to the image, ideal for observation at highest magnifications without changing objective lenses, for maintaining working distance and for framing of the smallest specimen detail.



MICROSCOPE LINEUP

A full product line-up for every purpose — even for special applications.





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BX41M-LED

BF DIC PO LEÓ ESD S

ESD-capable model with built-in LED illumination

The BX41M-LED with built-in bright and super long-life LED illumination has ESD capability to protect the device from electrostatic discharge.

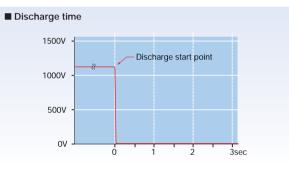
• LED illumination keeps natural color reproduction and a constant brightness during light adjustment or over lamp life span. • LED illumination provides improvement in throughput and reduction in running costs as optical adjustment is unnecessary and work does not have to be interrupted due to lamp burn-out. • LED illumination consumes less energy, 1/7 of that consumed by a 30W halogen lamp. Low power consumption also contributes to reduced CO2



LED illumination image



• ESD performance: surface resistance of 10⁸ ohm or less, discharge time of 0.2 sec or less* *When charged to 1000V and then discharged to 100V



• Equipped with 2 types of reflected light illuminators, BX-AKMA-LED (has an aperture stop and oblique illumination function) and BX-KMA-LED; oblique

illumination with the BX-AKMA-LED provides high-contrast images in a simple process.



Electric heating ribbon (20x observation



We, Olympus, certify products conforming to our

own enviromentally-counscious standards as ECO-PRODUCTS "Olympus Eco-products".



BX-REMCB

Control options include:

- the motorized revolving nosepiece.
- the motorized BF/DF Mode select and AS Open/Close via BX-RLAA or BX-RFAA

Those controls are made via the hand switch (U-HSTR2) or directly from the computer via RS232C format.



UIS2 OBJECTIVE LENSES Diverse lineup allows selection according to the purpose.

BX51-IR

BF IR Transmitted light

Near infrared (IR) light imaging

The BX51-IR allows non-destructive inspection and analysis of regions not visible to the naked eye. It facilitates non-destructive observation of specimens such as internals of silicon wafers and on the back of packages and CSP bumps.

• Lineup of 5x to 100x IR objective lenses which compensate for aberrations from visible to near infrared light.

• Provides reflected and transmitted near infrared light

observation model and reflected near infrared light observation model.

* Please contact your local Olympus dealer for IR camera system, large-size stage combination and system combination





100W halogen lamp housing for IR U-I H100IR) 2 Trinocular tube for IR (U-TR30IR) 3 Single port tube lens with lens for IR

(U-TLŪIR) Transmitted polarizer for IR I-POTIR)

S Rotatable analyzer slider for IR J-AN360IR) B Reflected polarizer slider for IR (U-POIR)

Band path filter (1100nm) for IR BP1100IR) 8 Band path filter (1200nm) for IR J-BP1200IR) Objective lenses for IR (LMPlan5xIR, MPlan10xIR, I MPlan20xIR, I MPlan50xIR, MPlan100xIR and MPlan100xIR) Connector to couple analyzer and polarizer

MX51

Offers the stage of 150 x 150mm travel area

The MX51 can be installed the MX-SIC6R2 150 x 150mm stage, which copes with larger and larger industrial field samples. It also accepts the universal illuminator BX-URA2 which includes fluorescence capability, or the reflected light brightfield/darkfield illuminator BX-RLA2.

- Since coarse/fine movement can be switched using the stage grip of the built-in clutch of the MX-SIC6R2, the microscope delivers extremely comfortable operational environment.
- SEMI S2/S8 compliance enhances safety and ergonomics.
- Olympus' front operation design concept guarantees high operability and reliability



BF DF DIC FL PO Transmitted 150mm stage





MPLAPON series

This is a Plan Apochromat objective lens series for brightfield The Plan Semi-Apochromat POL design ensures through observation with chromatic aberration corrected at high level. compensation for coma aberration. Distortion is also Olympus has assured that this series has the optical performance (wavefront aberration) with a Strehl ratio*1 of 95% or more*2 first in the world as a universal objective lens. This series is also compatible with a differential interference contrast or simple polarized observation.

MPLFLN-BDP series minimized, which makes these objective lenses the best choice for Nomarski DIC microscopy





MPLFLN (-BD) series

These Plan Semi-Apochromat objective lenses completely eliminate chromatic aberration at high level, which is perfect for a wide range of microscopic methods including brightfield (darkfield), fluorescence, Nomarski DIC and simple polarized observation. All 50x or higher objective lenses have 1mm working distance to fulfill safe approach to the specimen. Since exit pupil positions from 5x through 150x are standardized, no switching of the DIC prism lever position is necessary when the objective lens power changes



LMPLFLN (-BD) series

Long working distance Plan Semi-Apochromat objective lenses with a high level of chromatic aberration correction. Long working range up to the sample is effective with stepped samples and in preventing collision. Since exit pupil positions from 5x through 100x are standardized, no switching of the DIC prism lever position is necessary when the objective lens power changes



MPLN (-BD) series Plan Achromat objective lenses with excellent flatness up to F.N. 22. Use the BD series in brightfield and darkfield observation.





SLMPLN series Long working distance allows observation of fine line widths in high contrast observation with no chromatic shift.



LMPlan-IR, MPlan-IR series Plan Achromat objective lenses which compensate for aberrations from visible to near infrared light.

matched to the glass thickness is possible by using a correction collar.

Strehl ratio: When the light condensing ratio (central intensity) on the image field of an ideal aplanatic optical system is assumed as 100%, a light condensing ratio in % that an actual optical system can condense is known as Strehl ratio. The greater is this numeric value, the better becomes the quality of an optical system.

Strehl Ratio is guaranteed by the following conditions. Measurement : Transmitted Wavefront Interferometer (OLYMPUS in-house equipment) Temperature : 23 ± 1 centiorade Measurement Area : 97% in pupil diameter













Objective lenses	Magnifi- cations	N.A.	W.D. (mm)	Cover Glass Thickness*6 (mm)	Resolution*2 (µm)
MPLAPON	50x 100x	0.95 0.95	0.35 0.35	0 0	0.35 0.35
MPLFLN	1.25x*3*5 2.5x*3 5x 10x 20x 50x 100x	0.04 0.08 0.15 0.30 0.45 0.80 0.90	3.5 10.7 20.0 11.0 3.1 1.0 1.0		8.39 4.19 2.24 1.12 0.75 0.42 0.37
MPLFLN-BD*⁴	5x 10x 20x 50x 100x 150x	0.15 0.30 0.45 0.80 0.90 0.90	12.0 6.5 3.0 1.0 1.0 1.0		2.24 1.12 0.75 0.42 0.37 0.37
MPLFLN-BDP*4	5x 10x 20x 50x 100x	0.15 0.25 0.40 0.75 0.90	12.0 6.5 3.0 1.0 1.0	 0 0 0	2.24 1.34 0.84 0.45 0.37
LMPLFLN	5x 10x 20x 50x 100x	0.13 0.25 0.40 0.50 0.80	22.5 21.0 12.0 10.6 3.4		2.58 1.34 0.84 0.67 0.42
LMPLFLN-BD*4	5x 10x 20x 50x 100x	0.13 0.25 0.40 0.50 0.80	15.0 10.0 12.0 10.6 3.3		2.58 1.34 0.84 0.67 0.42
MPLN*3	5x 10x 20x 50x 100x	0.10 0.25 0.40 0.75 0.90	20.0 10.6 1.3 0.38 0.21	 0 0 0	3.36 1.34 0.84 0.45 0.37
MPLN-BD*1*3*4	5x 10x 20x 50x 100x	0.10 0.25 0.40 0.75 0.90	12.0 6.5 1.3 0.38 0.21	 0 0 0	3.36 1.34 0.84 0.45 0.37
SLMPLN	20x 50x 100x	0.25 0.35 0.6	25 18 7.6	0 0	1.34 0.96 0.56
LCPLFLN-LCD	20x 50x 100x	0.45 0.70 0.85	8.3— 7.4 3.0 — 2.2 1.2 — 0.9	0 — 1.2 0 — 1.2 0 — 0.7	0.75 0.48 0.39



Objective lenses	Magnifi- cations	N.A.	W.D. (mm)	Cover Glass Thickness* ⁶ (mm)	Resolution*2 (µm)
LMPIan-IR	5x 10x 20x 50x 100x	0.10 0.25 0.40 0.55 0.80	20.0 18.5 8.1 6.0 3.4		
MPlan-IR*3	100x	0.95	0.3	_	_

* "BD" = "Brightfield/darkfield" objective lenses

*6 — : Applicable to the view of specimens with/without a cover glass 0 : Applicable to the view of specimens without a cover glass

DIGITAL IMAGING SOLUTION

Greater efficiency up from observation to image capture and data analysis.



Microscope digital cameras **DP72**

With super-high, 12.8 megapixel resolution, the DP72 offers top-ofthe-line image clarity, detail and color depth. Advanced on-board cooling ensures the high sensitivity needed to capture clear images of any kind of sample, even dark ones.

Kev features: 12.8 megapixels ·Peltier cooling for highsensitivity performance with low noise Superb color reproduction and high resolution provide top-ofthe-line image quality .15 fps frame rate for fast, easy focusing and framing



DP25

This outstanding, high-resolution 5 megapixel color CCD camera includes accurate color reproduction and advanced color control among a wealth of features. It's also versatile enough for work with all types of samples. Olympus analySIS software is separately required to capture images.

Key features: 5 megapixels •Images in true color and accurate detail •Trimming the live image in a high resolution at high frame rates



DP20

The DP20 provides fast (15fps) motion imaging for precise color reproduction quality and highly efficient image acquisition in production line inspections. Even very fine structures are accurately captured and displayed with outstanding clarity.

Key features:

 2 megapixels •Standalone type (no PC required) saves space •Fast (15fps) frame rate for quick, easy focusing and framing •Equipped with measurement functions (distance between 2 lines, area of circle and between 2 circle centers distance) as standard

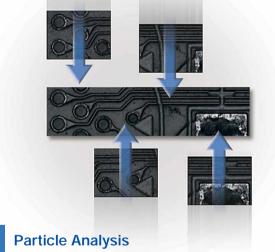
Olympus analySIS software

Seamless operation from image processing, measurement and analysis to database and report generation

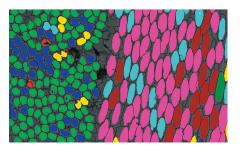
As one of the world leading microscope manufacturers, Olympus now offers the ideal software for analyzing digital images. Highly sophisticated — yet remarkable easy to use — the Olympus software is modular in form and adjustable to meet the needs of diverse applications. The integrated database is extremely powerful as it archives images along with all associated data. In addition to other standard features such as image acquisition, measurement/analysis and report generation, image stitching, focal imaging and many specialized materials characterization modules such as grain size and filter residue are available.

Stitching Images

Multiple adjacent images can be seamlessly and naturally stitched together into one — an easy, effective way of observing areas too large to be viewed as one image through the microscope.

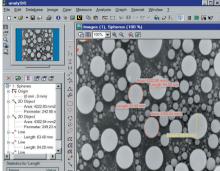


The separator function enables automatic separation of particles within an image, while threshold levels and detection areas are set though the ROI (region of interest). All particles are measured automatically, using a range of measurement parameters. The measurement data is statistically processed to enable high-level particulate analysis.





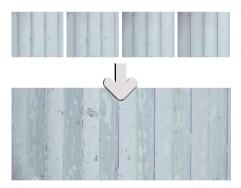
Counting particles...measuring dimensions...calculating the distance between two lines...analySIS software handles tasks like these with ease. Results can also be saved/output together with the images.





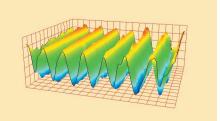
Extended Focal Image

Multiple versions of the same image, each focused at a different position, can be combined to produce a single, wholly-focused image. This function allows clear imaging of samples with different height levels on the surface, which cannot be observed all together at the same time conventionally.

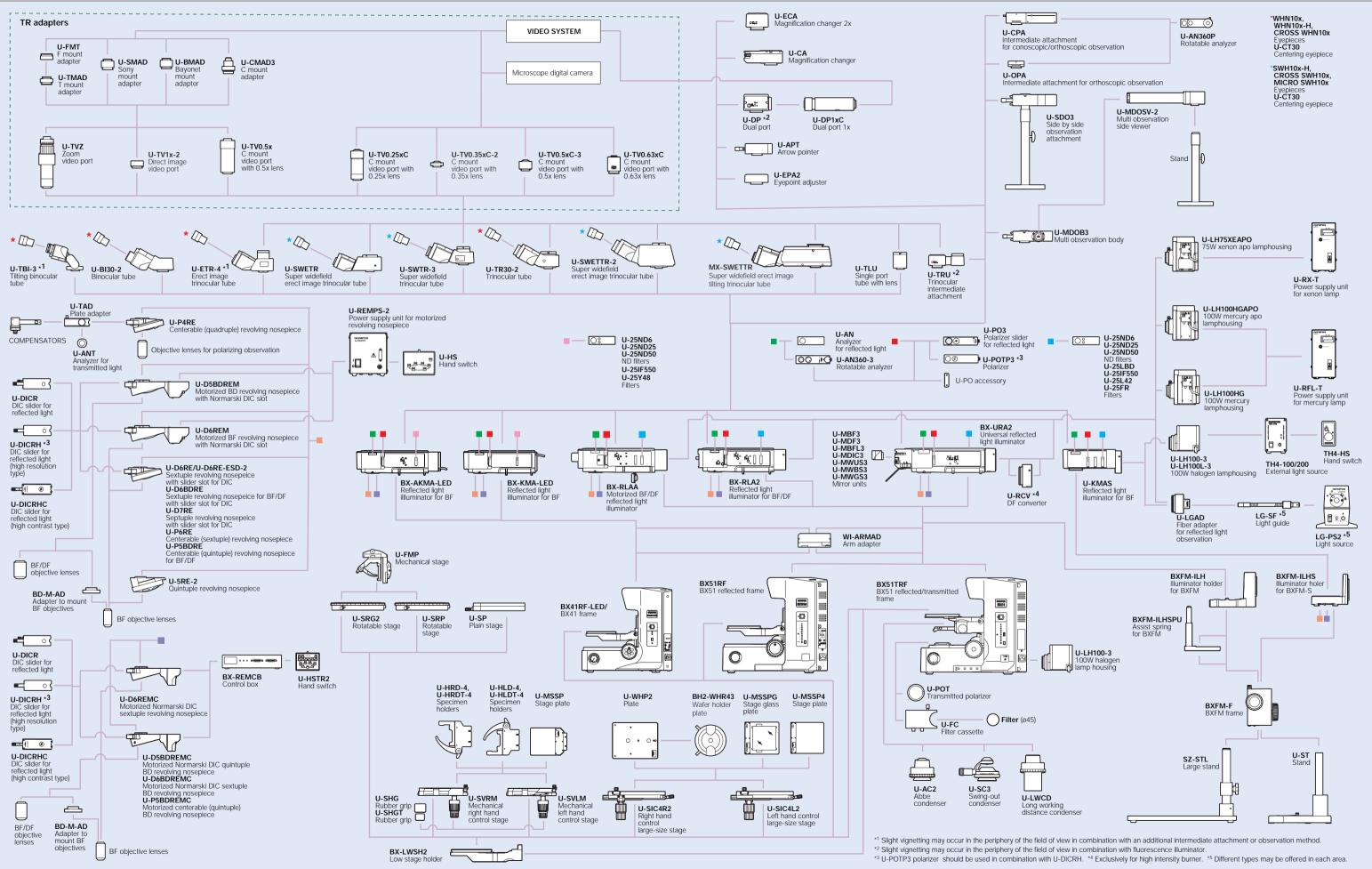


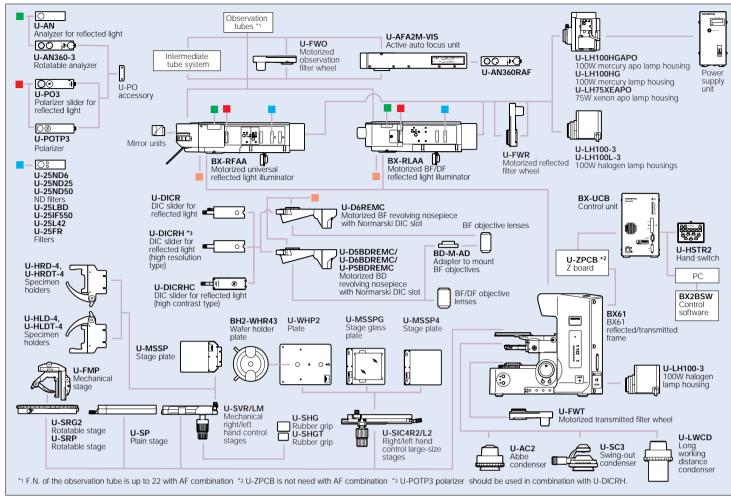


A uniformly focused image, obtained using the extended focal point function, can be used to construct 3D images and create real 3D animation. Magnification, reduction, pan, and rotation can be performed freely, allowing the specimen to be seen as a whole and examined from any angle.

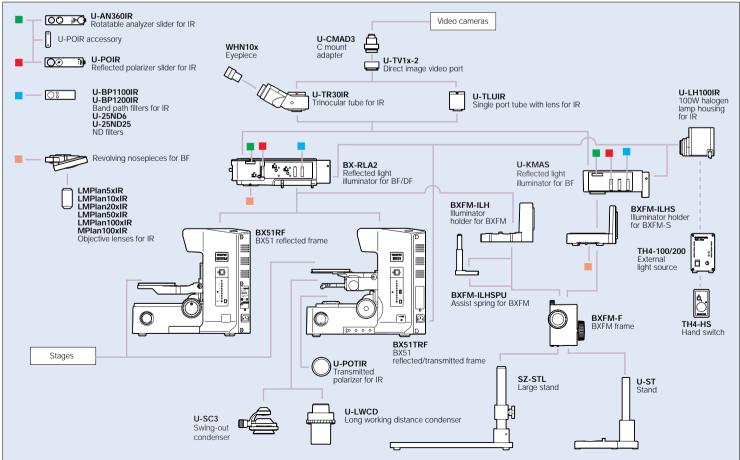


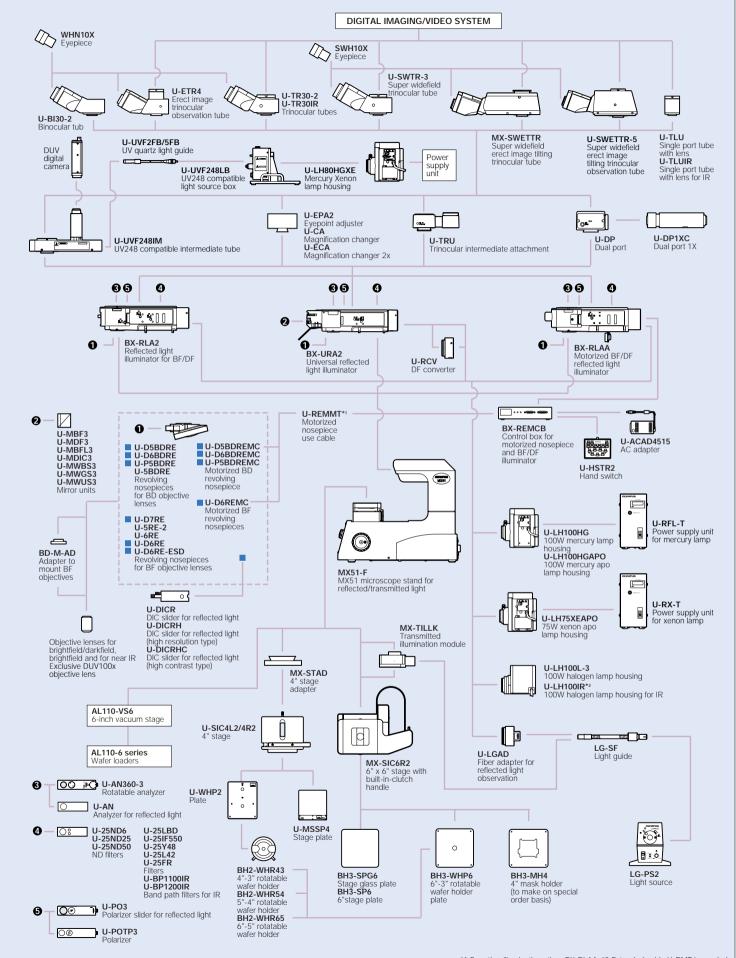
BX2M SYSTEM DIAGRAM





IR SYSTEM DIAGRAM





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MX51 SYSTEM DIAGRAM

BX61/BX51/BX51M/BX41M-LED-ESD specificatio

		BX61	BX51	BX51M	BX41M-LED	
Optical system		UIS2 optical system (infinity-correct	ted)		· ·	
Microscope	Illumination	Reflected	/transmitted	Reflected	Reflected (ESD capability)	
frame		External 12V100W light source Light preset switch LED voltage indicator Reflected/transmitted changeover switch	Built-in 12V100W light source Light preset switch LED voltage indicator Reflected/transmitted changeover switch	Built-in 12V100W light source Light preset switch LED voltage indicator	Built-in power supply for 3W white LED Light preset switch	
	Focus	Motorized focusing Stroke 35mm Minimum graduation 0.01µm	Stroke 35mm Fine stroke per rotation 100µm Minimum graduation 1µm With upper limit stopper, torque ac			
	Maximum sample height	25mm (v	v/o spacer)	(w/o spacer)		
Observation Widefield tubes (F.N. 22)		Inverted: binocular, trinocular, tilting binocular Erect: trinocular, tilting binocular				
	Super widefield (F.N. 26.5)	Inverted: trinocular Erect: trinocular, tilting trinocular				
Reflected light illumination	BF etc.	BX-RLAA Motorized BF/DF changeover Motorized AS	BX-RLA2 100W halogen (high intensity burner, fiber illuminator mountable) BF/DF/DIC/KPO FS, AS (with centering mechanism), BF/DF interlocking ND filter		BX-AKMA-LED/BX-KMA-LED 3W white LED BF/DIC/KPO ESD capable Following features are for BX-AKMA-LED only : KPO/oblique illumination AS (with centering mechanism) Oblique illumination position settings	
	Reflected fluorescence	BX-RFAA Motorized 6 position turret Built-in motorized shutter With FS, AS	BX-URA2 100W mercury lamp, 75W xenon lamp 6 position mirror unit turret (standard: WB, WG, WU+BF etc) with FS, AS (with centering mechanism), with shutter mechanism			
Transmitted light		100W halogen Abbe/long working distance conde Built-in transmitted light filters (LBD			_	
Revolving nosepieces	For BF	Motorized sextuple	Sextuple, centering sextuple, septuple (optional motorized revolving nosepieces)		Quintuple, sextuple (ESD capable) septipule	
	For BF/DF	Motorized quintuple, motorized sextuple, centering quintuple	Quintuple, centering quintuple, sextuple (optional motorized revolving nosepieces)		_	
Stages		Coaxial left(right) handle stage: 76(X)x52(Y)mm, with torque adjustment Large-size coaxial left (right) handle stage: 100(X)x105(Y)mm, with lock mechanism in Y axis				
Dimensions		Approx. 318(W) x 602(D) x 541(H)mm	Approx. 318(W) x 602(D) x 480(H)mm	Approx. 318(W) x 602(D) x 480(H)mm	Approx. 283(W) x 455(D) x 480(H)mm	
Weight		Approx. 25.5 kg (Microscope frame 11.4 kg)	approx. 20.8 kg (Microscope frame 10.3 kg)	Approx. 19.5 kg (Microscope frame 9.8 kg)	Approx. 14 kg (Microscope frame 6.7 kg)	

BXFM specifications

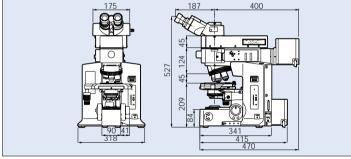
		BXFM	BXFM-S		
Optical system		UIS2 optical system (infinity-corrected)			
Microscope Focus frame		Stroke 30mm, Fine stroke per rotation 200µm, Minimum graduation 2µm, with torque adjustment for coarse handle			
Observation Widefield (F.N. 22)		For inverted image: binocular, trinocular, tilting binocular For erect image: trinocular, tilting binocular			
	Super widefield (F.N. 26.5)	For inverted image: trinocular For erect image: trinocular, tilting trinocular			
Reflected light illumination	BF etc.	BX-RLA2 100W halogen (high intensity burner, fiber illuminator mountable) BF/DF/DIC/KPO FS, AS (with centering mechanism), with shutter mechanism	U-KMAS 100W halogen fiber illumination BF/DIC/KPO		
	Reflected fluorescence	BX-URA2 100W mercury lamp, 75W xenon lamp 6 position mirror unit turret (standard: WB, WG, WU+BF etc) with FS, AS (with centering mechanism), with shutter mechanism	_		
Revolving	For BF	Sextuple, centering sextuple, septuple (optional motorized revolving nosepieces)			
nosepiece	For BF/DF	Quintuple, centering quintuple, sextuple (optional motorized revolving nosepieces)			
Dimensions		Approx. 248 (W) x 587 (D) x 249 (H) mm	Approx. 394 (W) x 334 (D) x 276 (H) mm		
Weight		Approx. 9kg (standard combination)	Approx. 6.2kg (standard combination)		

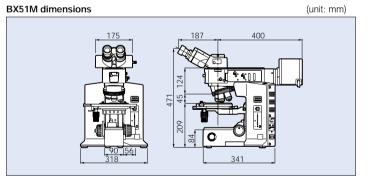
MX51 specifications

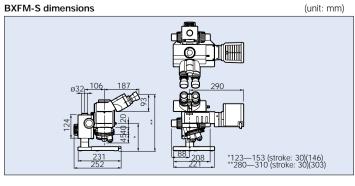
	UIS2 optics (infinity-corrected system)			
e stand	2-guide rack and pinion method Coarse and fine co-axial Z-axis control stroke 32mm (2mm upper and 30mm below from the focal plane) The same stroke 15mm (combination with transmitted illumination) Stroke per rotation of fine Z-axis control 0.1 mm (1 unit 1µm) Coarse handle torque adjustment Coarse handle upper limit lever			
	BX-RLA2 Brightfield/Darkfield illuminator	BX-URA2 Universal Fluorescence illuminator		
Contrast changeover method	BF-DF slide method	Mirror (Max. up to 6) turret method		
Applicable observation mode	 Brightfield Darkfield Nomarski DIC Polarized light IR 	 Brightfield Darkfield Nomarski DIC Polarized light Fluorescence 		
ng	12V100W Halogen Lamphouse: U-LH100L-3	Mercury lamp house: U-LH100HGAPO External power supply BH2-RFL-T3 needed Power supply is integrated in MX51		
d illumination	Brightfield MX-TILLK combined with fiber light guide illumination (configured with MX-SIC6R2)			
oly unit Continuous light intensity dial	Rated voltage: 100-120/220-240V~1.8A/0.8A 50/60Hz			
tube	U-BI30-2 Widefield binocular, U-TR30-2 Widefield trinocular, U-ETR4 Widefield erect image trinocular (F.N. 22) U-SWTR-3 Super widefield trinocular, MX-SWETTR/U-SWETTR-5 Super widefield erect image tilting trinocular (F.N. 26.5)			
osepiece	U-5RE-2, U-6RE U-D5BDRE, U-D6BDRE, U-P5BDRE (with slider slot for DIC Prism)			
	U-SIC4R2/SIC4L2 Coaxial right/left-hand control 4" x 4" stage	MX-SIC6R2 Coaxial right/left-hand control 6" x 6" stage		
	Drive method: rack and pinion method Y axis stopper: lever method	Drive method: Belt method Stroke: 158(X) x 158 (Y) mm Clutch method: 2 clutch plates (Built-in-clutch ON/OFF handle) Holder dimensions: 200 x 200mm Transmitted light area: 100 x 100mm		
/weight	Dimensions: Approx. 430(W) x 591(D) x 495(H)mm Weight: Approx. 26kg (Stand Approx. 11kg)			
	Contrast changeover method Applicable observation mode	stand 2-guide rack and pinion method Coarse and fine co-axial Z-axis control stroke 32mm (2mm up The same stroke 15mm (combination with transmitted illuminal Stroke per rotation of fine Z-axis control 0.1 mm (1 unit 1µm) Coarse handle upper limit lever BX-RLA2 Brightfield/Darkfield illuminator Contrast changeover method Applicable observation mode ① Brightfield ② Darkfield ③ Nomarski DIC ④ Polarized light ⑤ IR ng 11llumination Brightfield MX-TILLK combined with fiber light guide illuminatio obly unit Continuous light intensity dial n tube U-BI30-2 Widefield binocular, U-TR30-2 Widefield trinocular, U U-SBDRE, U-D6BDRE, U-P5BDRE (with slider slot for DIC Pr U-SBC4R2/SIC4L2 Coaxial right/left-hand control 4" x 4" stage Drive method: rack and pinion method		





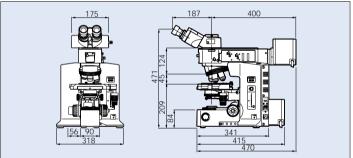






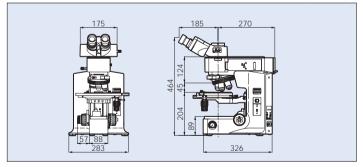
BX51 dimensions

(unit: mm)



BX41M-LED+BX-AKMA-LED dimensions

(unit: mm)



MX51 dimensions

